

| | Type | L # | Hits | Search Text | DBs | Time Stamp | Co mm en ts | Er ro r De fi ni ti on | Er ro rs |
|---|------|-----|------|--|---|---------------------|----------------------|---|----------------|
| 1 | BRS | L2 | 1 | metal near gate and ((oxide near mask with nitride near mask) or double near mask or dual near mask) and oxide with mask with (ald or atmic adj layer adj deposit\$4) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/05/02 04:38 | | | |
| 2 | BRS | L3 | 2 | metal near gate and ((oxide near mask with nitride near mask) or double near mask or dual near mask) and (ald or atomic adj layer adj deposit\$4) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/05/02 04:44 | | | |

| | Type | L # | Hits | Search Text | DBs | Time Stamp | Comments | Error Definition | Errors |
|---|------|-----|------|---|---|---------------------|----------|------------------|--------|
| 3 | BRS | L1 | 26 | metal near gate and ((oxide near mask with nitride near mask) or double near mask or dual near mask) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/05/02 04:40 | | | |
| 4 | BRS | L4 | 2 | metal with gate and ((oxide near mask with nitride near mask) or double near mask or dual near mask) and (ald or atomic adj layer adj deposit\$4) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/05/02 04:44 | | | |
| 5 | BRS | L5 | 3 | metal and gate and ((oxide near mask with nitride near mask) or double near mask or dual near mask) and (ald or atomic adj layer adj deposit\$4) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/05/02 04:45 | | | |

| | Type | L # | Hits | Search Text | DBs | Time Stamp | Co mm en ts | Er ro r De fi ni ti on | Er ro rs |
|---|------|-----|------|--|---|---------------------|----------------------|---|----------------|
| 6 | BRS | L6 | 3 | gate and ((oxide near mask with nitride near mask) or double near mask or dual near mask) and (ald or atomic adj layer adj deposit\$4) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/05/02 04:46 | | | |
| 7 | BRS | L7 | 5 | ((oxide near mask with nitride near mask) or double near mask or dual near mask) and (ald or atomic adj layer adj deposit\$4) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/05/02 04:48 | | | |
| 8 | BRS | L8 | 1 | ((oxide with mask and nitride near mask) or double near mask or dual near mask) with (ald or atomic adj layer adj deposit\$4) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/05/02 04:49 | | | |

| | Type | L # | Hits | Search Text | DBs | Time Stamp | Comments | Error Definition | Errors |
|----|------|-----|------|--|---|---------------------|----------|------------------|--------|
| 9 | BRS | L11 | 2 | metal near gate and ((oxide with mask and nitride near mask) or double near mask or dual near mask) and (ald or atomic adj layer adj deposit\$4) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/05/02 04:49 | | | |
| 10 | BRS | L10 | 23 | gate and ((oxide with mask and nitride near mask) or double near mask or dual near mask) and (ald or atomic adj layer adj deposit\$4) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/05/02 04:49 | | | |

| | Type | L # | Hits | Search Text | DBs | Time Stamp | Co mm en ts | Er ro r De fi ni ti on | Er ro rs |
|----|------|-----|------|---|---|---------------------|----------------------|---|----------------|
| 11 | BRS | L9 | 27 | ((oxide with mask and nitride near mask) or double near mask or dual near mask) and (ald or atomic adj layer adj deposit\$4) | US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB | 2005/05/02 04:52 | | | |